

MICRO-623

Modelling micro-/nano- field effect electron devices

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Cursus	Sem.	Type
Microsystems and Microelectronics		Obl.

Language of teaching	English
Credits	1
Session	
Exam	Written
Workload	30h
Hours	14
Courses	14
Number of positions	20

Frequency

Every 2 years

Remark

Next time in June 2020

Summary

The course provides an in depth modeling of emerging field effect transistors in CMOS technology. Starting from the basis, the course will gradually introduce essential aspects to end up with a rigorous description of key features, Nanowire FET & its application to biosensing will also be analyzed.

Content

- A) Bulk MOSFETs
 - I) The concept of inversion charge linearization
 - II) Transcapacitances and charge partitioning
 - III) Short channel effects
- B) Multigate inversion mode MOSFETs
 - I) Electrostatics in double gate architectures
 - II) Quantum confinement corrections in DG FETs
 - III) Modelling cylindrical inversion mode MOSFETs
 - IV) Modeling arbitrary geometries MOSFETs
- C) Junction-Less FETs (depletion-accumulation mode FETs)
 - I) Electrostatics in JL Double Gate junction less FET architectures
 - II) Modeling the nanowire JL FET
 - III) JL nanowires for bio-sensors (including surface/interface traps)
- D) Transport at the nano-scale
 - I) Introduction to quantum conductance
 - II) Conceptual modeling of a 'molecular FET'
 - III) Basics of ballistic transport

Keywords

multigate MOSFET, junctionless FET, nanowires, bio-sensors, ballistic transport

Learning Prerequisites**Recommended courses**

Basic course in maths, physics